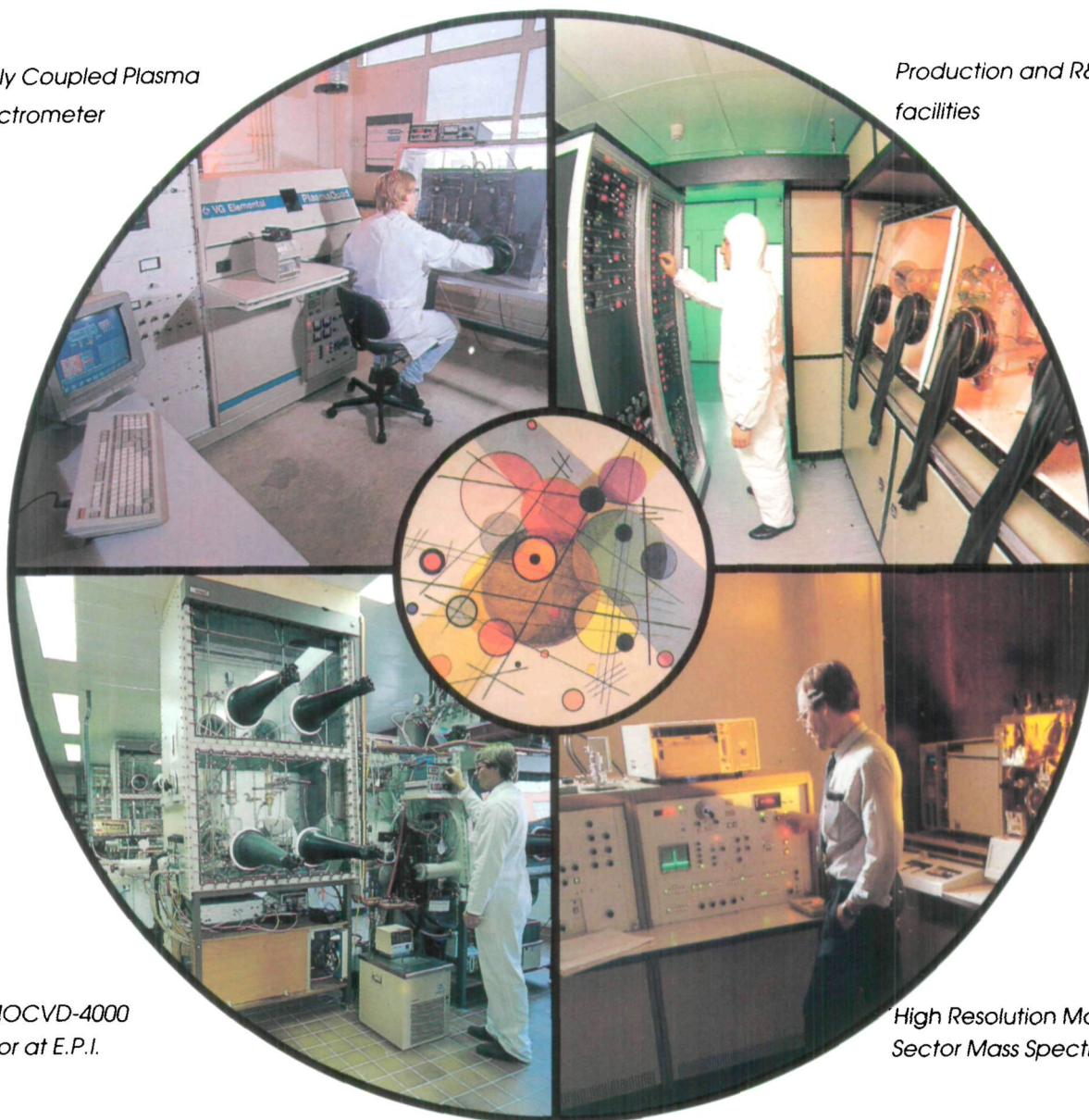


Organometallics for Electronics

Inductively Coupled Plasma
Mass Spectrometer

Production and R&D
facilities



CVT-MOCVD-4000
Reactor at E.P.I.

High Resolution Magnetic
Sector Mass Spectrometer

Organometallics produced and analysed by Billiton Precursors B.V.* are tested by Epitaxial Products International Ltd. ensuring products of consistent high performance. A Certificate of Analysis and a Certificate of Performance are supplied with each batch.

- TMG** Typical 77K mobility for GaAs (100 mbar, 650°C, V/III=110): $>120.000 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$
- TMA** Typical 10K FWHM of Bound Exciton for $\text{Al}_{0.25}\text{Ga}_{0.75}\text{As}$ (1000 mbar, 750°C, V/III=36): $<5 \text{ meV}$
 Typical 5K FWHM of Bound Exciton for $\text{Al}_{0.10}\text{Ga}_{0.90}\text{As}$ (1000 mbar, 800°C, V/III=15): $<4 \text{ meV}$
- TMI** To follow shortly



Billiton Precursors B.V.

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IN R&D, THE FUTURE BELONGS TO THE FLEXIBLE



▲ A typical UHV internal arrangement for co-sputtering.

▼ Model 6000 modular UHV deposition system.

For as much as superconductivity is changing the future, there will also be changes in the projects you're working on.

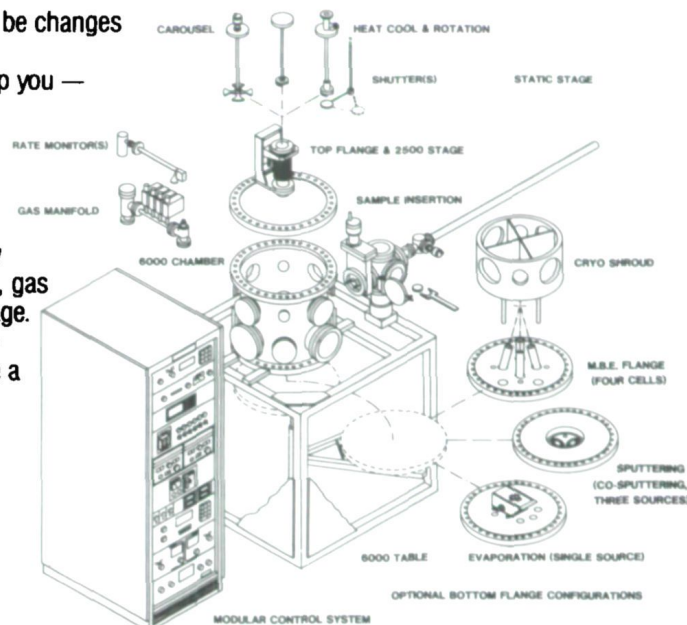
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